

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of)	MAIL STOP AF
)	
Shenggao Liu et al.)	Group Art Unit: 1795
)	
Application No.: 10/764,407)	Examiner: Cynthia Hamilton
)	
Filed: January 23, 2004)	Confirmation No.: 9511
)	
For: PHOTORESIST COMPOSITIONS)	
COMPRISING DIAMONDOID)	
DERIVATIVES)	
)	

AMENDMENT AFTER NOTICE OF APPEAL

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Further to the Notice of Appeal filed on April 28, 2008, Applicants submit the following
Amendment to place the application in condition for allowance.

A Listing of Claims begins on page 2 of this Response.

Remarks begin on page 7 of this Response.